分項名稱 Section Name: 放棄註冊商標 (局部放棄) Surrender of Registered Trade Mark(s) (Partial Surrender)



香港特別行政區政府知識產權署商標註冊處

Trade Marks Registry, Intellectual Property Department
The Government of the Hong Kong Special Administrative Region

放棄註冊商標 (局部放棄)

根據《商標條例》(第 559 章)第 56 條及《商標規則》(第 559 章附屬法例)第 56 條,以下註冊商標的擁有人已就某些該等註冊所關乎的貨品或服務放棄註冊。

SURRENDER OF REGISTERED TRADE MARK (S) (PARTIAL SURRENDER)

The registrations of the following registered trade mark(s) have been surrendered by the owner(s) under section 56 of the Trade Marks Ordinance (Cap. 559) and rule 56 of the Trade Marks Rules (Cap. 559 sub. leg.) in respect of certain goods or services for which the trade mark(s) are registered.

[111] **註冊編號:** 301257534AA

Trade Mark No.:

[540] **商標**: Mark:

ASML NXT

[571] **商標描述:** N/A

Mark Description:

[730] 擁有人姓名/名稱、 ASML NETHERLANDS B.V.

地址: DE RUN 6501 5504 DR VELDHOVEN NETHERLANDS

Owner's Name,

Address:

[740/ 擁有人的送達地址: Owner's WENPING & CO.

750] Address for Service: 1701 Tung Wai Commercial Building, 111 Gloucester Road,

HONG KONG

[511] 類別編號: 7

Class No.:

[151] 註冊日期: 15-12-2008

Date of Registration:

放棄生效日期: 06-10-2010

Date of Surrender Taking

Effect:

放棄註冊所關乎的下列貨品或服務:

Surrendered in respect of the following goods or services for the registration:

類別 Class 7

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Micro-lithography equipment; machines for use in industry in the field of electronics, integrated circuits, semi-conductors, magnetic domain memory and integrated optical systems industries; parts, fittings and accessories for all of the aforesaid goods; except semi-conductor lithographic machines, and their parts and fittings.

紀錄冊內的貨品或服務現修改如下:

The remaining goods or services on the register now read as follows:

類別 Class 7

semi-conductor lithographic machines, and their parts and fittings.